

1
2
3 **Electrical and magnetic properties of silicon carbide composites with titanium and**
4
5 **niobium carbide as sintering aids**
6
7

8 R. Bystrický^{1, 6, *}, M. Škrátek², J. Rusnák^{1, 3}, M. Precner⁴, M. Ťapajna⁴, M. Hnatko^{1, 5}, P.
9 Šajgalík^{1, 5}
10
11

12
13
14 ¹Institute of Inorganic Chemistry, Slovak Academy of Sciences, Dúbravská cesta 9, 841
15
16 04 Bratislava
17

18
19
20 ²Institute of Measurement Science, Slovak Academy of Sciences, Dúbravská cesta 9,
21
22 841 04 Bratislava
23

24
25
26 ³Institute of Physics, Slovak Academy of Sciences, Dúbravská cesta 9, 841 04,
27
28 Bratislava
29

30
31
32 ⁴Institute of Electrical Engineering, Slovak Academy of Sciences, Dúbravská cesta 9,
33
34 841 04 Bratislava
35

36
37
38 ⁵Centre for Advanced Materials Application (CEMEA), Slovak Academy of Science
39
40 (SAS), Dúbravská cesta 9, 841 04, Bratislava, Slovakia
41

42
43 ⁶Laboratory for Advanced materials, Faculty of Natural Sciences, Comenius University,
44
45 842 15 Bratislava, Slovakia
46

47
48
49 **Abstract**
50

51
52 Silicon carbide based composites with 30, 40 and 50 wt. % of Ti and NbC as sintering
53
54 additives were prepared by hot-press method. Molar ratio of Ti:NbC was kept at 1:1.8.
55
56
57

58
59
60

61 * *Corresponding author.* Tel. Tel.: +421-2-59410-427; fax: +421-2-59410-444
email: roman.bystricky@savba.sk (Roman Bystrický)

1 The two step sintering was performed in order to avoid the squeezing out the melted
2 titanium above 1668 °C. Composite powders were sintered at 1650 °C for 3 h and
3
4 subsequently at 1850 °C for 1 h under mechanical pressure of 30 MPa in Ar atmosphere.
5
6 XRD pattern confirmed the formation of (Ti, Nb)C_{ss} in the SiC matrix. Composite with
7
8 50 % of Ti-NbC phase showed the extraordinary electrical conductivity of 2.4×10^5 S/m
9
10 which was achieved by homogeneous distribution of Ti and NbC in SiC matrix and
11
12 forming a continuous conductive network. Prepared composites show complex magnetic
13
14 properties, diamagnetism originated from SiC matrix, paramagnetism caused by Ti and
15
16 NbC admixing, as well as weak ferromagnetism probably coming from impurities
17
18 contained in the initial powders. Samples with 30 and 40 wt. % of Ti and NbC exhibit
19
20 superconducting state below 2 K.
21
22
23
24
25

26
27 **Keywords:** silicon carbide (D), niobium carbide (D), electrical conductivity (c), hot
28
29 pressing (A)
30
31
32
33
34
35
36

37 1. Introduction

38
39
40 Increasing the electrical conductivity of structural ceramics is important for applications
41
42 that require manufacturing components with complex shapes using the electro-discharge
43
44 machining (EDM) technique [1-3].

45
46 The electrical conductivity of ceramics can be influenced mainly by the composition of
47
48 grain boundary phase [4-8] as well as by processing conditions [9]. Kim et al. [10]
49
50 achieved the electrical conductivity of SiC (3×10^4 S/m) by nitrogen doping resulting
51
52 from Y(NO₃)₃ as a sintering additive.
53
54

55
56
57 A promising approach of influencing the electrical conductivity is a combination of
58
59 insulating engineering ceramics with electrically conductive phases. Incorporation of
60
61

1 carbon nanostructure (carbon fiber, carbon nanotubes, graphene) into the ceramic matrix
2 led to the improvement of the electrical conductivity of ceramics [11-17]. These
3 nanostructures can form the conductive network within the matrix and can significantly
4 increase the electrical conductivity. On the other hand, there are difficulties with
5 homogeneous distribution of these carbon nanostructures in the matrix and for composites
6 with higher amount of carbon nanostructures is difficult to reach fully dense materials.
7 Both issues result in the degradation of mechanical properties of the prepared composites.
8
9 Another good candidate for increasing of the electrical conductivity of ceramics is
10 niobium carbide which has high electrical conductivity (13.5×10^3 S/m) as pure phase
11 [18]. In addition, it possesses high stability, high hardness and high wear resistance.
12 Moreover, in combination with Ti helps to densify the SiC ceramics and can significantly
13 increase the electrical conductivity of resulted material [19]. Ti forms TiC at high
14 temperatures, which is another phase with high stability, high hardness and high wear
15 resistance.
16
17 Several papers were published during last years, where Ti and NbC were added into SiC
18 matrix to increase the electrical conductivity of resulting composite [19, 20].
19
20 Balog et al. prepared such composites and they studied the influence of addition of Ti and
21 NbC into the SiC matrix on the mechanical and electrical properties. The amount of Ti
22 and NbC addition varied from 10 to 90 wt. %. AlN and rare earth oxides were used as
23 sintering additives. Their amount was kept at 13 wt. %. Two step sintering was used in
24 order to densify composite materials, at first the samples were heated up to 1650 °C for
25 3h and subsequently at 1850 °C for 1h. The hardness and fracture toughness were not
26 substantially changed by the addition of the Ti and NbC phases up to 50 wt. %. An almost
27 linear increase of electrical conductivity up to 80 wt. % of the electrically conductive
28 phase was observed where 4×10^4 S/m was achieved [20].
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

Frajkorova et al. prepared SiC-Ti-NbC composites where no oxide additives were used as sintering additives. Composites with 30, 40, and 50 wt. % of Ti and NbC phase, were sintered at 1850 °C for 1h. Only sample with 50 wt. % of addition of Ti and NbC was fully dense and electrical conductivity reached 3.06×10^4 S/m [19].

Present paper has an ambition to present the results of the preparation of the SiC based ceramics with increased electrical conductivity at room temperature and superconductivity at the temperature characteristic for NbC and Ti metals. The appropriate addition of NbC and Ti to the SiC ceramics for reaching these goals will be discussed. Functional properties of ceramics were measured by different methods of physics.

2. Experimental section

2.1. Preparation of composites

The commercially available powders of β -SiC (HSC-059, Superior Graphite, USA, mean diameter of 0.55 μ m), Ti (TOHO Titanium Co., Japan, mean diameter of 5-10 μ m) and NbC (Japan New Metals Co., Japan, mean diameter of 1 μ m) were used for the starting mixtures preparation. Impurities in the initial powders (Tab. 1) were determined by X-ray fluorescence spectrometry (ARL Advant'X Intellipower 3600 Wavelength Dispersive X-ray Fluorescence WDXRF).

The SiC-based composites were prepared by the addition of the various amount of electrically conductive Ti-NbC phase (mixture of Ti and NbC in a molar ratio 1:1.8). The chemical composition of starting mixtures is briefly listed in Table 2.

Appropriate amounts of SiC, Ti and NbC were homogenized in distilled water with WC balls by planetary ball mill (Retsch PM 100) at 150 rpm for 1 h. Then such prepared

1 suspensions were sprayed immediately into the liquid nitrogen in order to prevent
2 separation of phases with different densities (Tab. 3) and subsequently frozen powders
3 were freeze dried.
4
5

6
7 The pre-pressed pellets were hot pressed in two steps: at 1650 °C for 3 h and at 1850 °C
8 for 1 h under mechanical pressure of 30 MPa in Ar atmosphere. Reference sample without
9 any additives was prepared by hot-press at 1850 °C. Details of sintering process are
10 described in Ref. 21.
11
12

13 *2.2. Microstructural characterization*

14 The densities of the samples were measured by Archimedes method in mercury. The
15 theoretical densities were calculated according to the rule of mixtures.
16

17 The microstructures were observed by scanning electron microscopy EVO 40HV (Karl
18 Zeiss, Germany). For this purpose, the sintered samples were cut, polished and etched on
19 Femto plasma system (Diener Electronic, Germany, O₂:CF₄ = 3:7).
20

21 Direct microstructural investigations were performed on a probe-corrected Titan Themis
22 300 (FEI/ThermoFisher Scientific, USA) transmission electron microscope in scanning
23 mode (STEM) at 200 kV accelerating voltage equipped with the EDS system (Super-X).
24 EDS spectrum images were acquired by serially scanning across a defined area of the
25 specimen and recording cumulative EDS spectra at each position.
26

27 Samples were polished (to electron transparency) using an ion mill PIPS 691 (Gatan,
28 USA).
29

30 The crystalline phases present in the ground samples were identified using X-ray
31 diffraction (XRD) (Panalytical Empyrean, Netherlands, Cu K α radiation).
32
33

34 *2.3. Electrical resistivity*

1 Samples were cut into 10 mm x 10 mm x 0.3 mm square-shaped pieces. Then small
2 Indium balls for preparation of the contacts were placed into the sample corners and
3
4 annealed at 300 °C for 3 min in N₂ atmosphere to remove the moisture from the samples.
5
6 The *dc* measurement at ambient conditions were performed by standard four-point Van
7 der Pauw method [22].
8
9

10 For the temperature dependent electrical conductivity, samples were placed into the
11 holder and the resistor heater was used to perform the measurements under variable
12 temperature (320 – 440 K) under vacuum (10 Pa). The *ac* conductivity was measured
13 with 2 probe method. The data were obtained by collecting the impedance using the LCR-
14
15 meter WK 6500B (WayneKerr, UK) at frequency of 1 kHz with the bias current of 100
16
17 mA. The upper contact on the sample was made up of the gold-plated tip, the bottom
18 contact was formed by a chrome-plated copper plate. The leads from this contact are led
19 to the BNC connectors and then to the LCR meter. Contacts of samples were created by
20 Au-sputtering using Hummer II (Technics EMS, Inc., USA). Fig. 1 shows the schematic
21 diagram of the measuring system.
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36

37 *2.4. Spreading resistance imaging (SRI)*

38
39 The SRI was evaluated in the scanning system NTegra (NT-MDT Spectrum Instruments,
40 Russia). SRI is an electrical characterization technique, based on scanning probe
41 microscopy (SPM) to probe the two-dimensional resistivity distribution. Measurements
42 were performed in contact mode with platinum coated conducting tip at constant force
43 mode under nitrogen atmosphere to investigate the electrical response of the sample.
44
45 Before the characterization, sample was ion beam etched using an ion mill PIPS 691
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

66 *2.5. Magnetic measurements*

1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

Magnetic properties were measured using a MPMSXL7 SQUID magnetometer (Quantum Design, USA) operating in the 1.8 - 300 K range. Isothermal magnetization vs. field curves, $M(H)$, were measured up to 7 T field at two different temperatures 2 and 300 K. Magnetization vs. temperature curves were measured in two ways: at first, the sample was cooled down from room temperature (RT) to 5 K without applying any magnetic field (using ultra low field option to set zero field) and then heated back to RT under applied magnetic field of 5 mT (zero field cooled - ZFC curve); afterwards, under the same field the sample was cooled down again to 5 K and the magnetization was measured, following the same steps as before (field cooled - FC curve). The data were corrected to contribution of sample holder and normalized to weight of the samples.

3. Results and discussion

Table 4 shows the densities of sintered samples. Sample SiCN30 has 91.7 % of theoretical density. Samples with addition of 40 and 50 mass % of Ti-NbC phase were almost fully dense, with relative densities higher than 97 %. It is evident that the relative density of the composites is increasing with the addition of Ti-NbC.

3.1. Microstructure and XRD analysis

XRD analysis showed that the SiC is present in the composites in two modifications, as β -SiC and α -SiC which is a result of β - α transformation. Ti and NbC are present in the composites as a (Ti, Nb) C_{ss} . Amount of α -SiC in composites is increasing by increasing of (Ti, Nb) C_{ss} content. Small amount of NbSi₂ phase was detected in all samples. We assume that Nb from NbC formed alloy with Si present as impurity in the starting powders (Tab. 1).

1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

Microstructures of a polished and plasma etched surface of the SiCN composites are shown in the Fig. 4. The microstructures are composed from equiaxed and elongated SiC grains (dark grey) and from grains of (TiNb)C_{ss} which are overetched. Between SiC grains there is grain boundary phase which is visible especially in SiCN50 composite. The presence of elongated SiC grains suggests its transformation from β to α . This is in agreement with XRD analysis. SiCN30 composite (Fig. 4a) contains some pores which corresponds to lower relative density of this sample. Some grains are pulled out from the surface of the SiCN40 and SiCN50 composites during grinding and polishing.

3.2. *Transmission electron microscopy*

TEM image and map of elements of the SiCN50 are shown in the Fig. 5. In the TEM image SiC grain and TiNbC grains are visible. On the grain boundary there are triple points with two different compositions. In the first type, Al, Ca, Si and O elements were detected. This indicates the formation of SiO₂-Al₂O₃-CaO glass during densification. The presence of these elements in the triple point is surprising because their content in the starting powder is a few hundreds of ppm (Tab. 1). However, high local concentration of these elements can be explained by its segregation during the densification process. Similar segregation of aluminum in the triple points of SiC or iron in the Si₃N₄ ceramics were observed earlier [21, 23].

On the other hand, there is a Fe, Co, Nb and Si rich region in the second type of triple points. Due to the absence of oxygen, we expected that Fe_{1-x}Co_xSi alloys were formed based on ternary phase diagram (Fig. 6) [24].

From these results we assume that SiO₂-Al₂O₃-CaO and Fe_{1-x}Co_xSi subsystems can form a liquid phase (above 1200 °C) and can help to densify the SiC-Ti-NbC system. Also, the

1 partial β - to α -SiC phase transformation of composites supports the formation of liquid
2 phase.
3
4
5

6 7 *3.3. Electrical conductivity* 8

9
10 Fig. 6 shows the room temperature DC electrical conductivity of SiCN composites as a
11 function of TiNbC content. For monolithic SiC ceramic material, the electrical
12 conductivity is around 110 S/m at room temperature. This value may be explained by the
13 presence of turbostratic carbon areas in the triple points and also by the presence of the
14 graphene layer on the grain boundaries [21]. This graphene layer can increase the
15 electrical conductivity of the composites as it was published earlier [25]. With the
16 incorporation of the 30 and 40 wt. % TiNbC electrical conductivity was enhanced to 1.9
17 $\times 10^4$ S/m and 6.9×10^4 S/m, respectively. The electrical conductivity of the SiC/TiNbC
18 composite experienced a dramatic increase to around 2.4×10^5 S/m, when the mass
19 fraction of TiNbC reached 50 %. The conduction behavior of SiC/TiNbC composites
20 showed a typical percolation feature. Above the percolation threshold, a conductive
21 network was formed and thus a significantly enhanced conductivity was obtained.
22 Electrical conductivity achieved in this work is the highest value of the conductivity of
23 SiC composites comparing to other published values.
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42

43
44 If we compare our results with the values achieved by Frajkorova et al. [19] where the
45 same composition of the composites was used, we can say that the freeze drying and two
46 step sintering method resulted to the improvement of the electrical conductivity of the
47 composites (in case of SiCN50 two order of magnitude higher value in our work).
48
49
50
51
52
53
54
55

56 Fig. 7 shows the temperature dependence of the electrical conductivity of the SiC
57 composites compared to monolithic SiC. The conductivity of the samples slightly above
58
59
60
61
62
63
64
65

1 room temperature (320K) is one order of magnitude lower than the values measured at
2 room temperature (Fig. 6). This difference in the values can be explained as a result of
3 different method used for investigation of room temperature and temperature dependent
4 conductivity. While at room temperature DC conductivity measurements method was
5 used, temperature dependent conductivity was collected by AC conductivity
6 measurement.
7
8
9
10
11
12

13 The SiC composites exhibited semiconductive behavior above room temperature, i. e.
14 increasing conductivity with increasing temperature. The same behavior was found for
15 the monolithic SiC. Despite the fact that pure TiC and NbC exhibit metal behavior
16 conductivity, prepared composites exhibited semiconductive behavior (according to
17 temperature dependent conductivity). This indicates that the electrical current is led
18 through SiC grains. On the other hand, the addition of TiNbC significantly increased the
19 electrical conductivity of composite, so the TiNbC phase must play the role in the
20 conductivity of the composite.
21
22
23
24
25
26
27
28
29
30
31
32

33 *3.4. Atomic force microscopy*

34
35
36 Fig. 8 a-b show the atomic force microscopy (AFM) image and the current distribution
37 image, respectively, for the electrically conductive SiC with addition of the 50 mass % of
38 Ti-NbC. On the image of the topography (Fig. 8a) SiC grains and (TiNb)C_{ss} grains
39 correspond to the dark and bright areas, and in the current distribution image, the surfaces
40 of the low and high electrically conductive materials correspond the dark and bright areas,
41 respectively. For the applied voltage ($V_{tip} = + 2.5$ V) Fig. 8b shows two distinguishable
42 phases - conductive with current around 20-30 nA and less conductive with current
43 around 10 nA. As it can be observed, there is a good correlation between topography and
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

1 current. Comparing the current map with topography the more conductive phase is in
2 topography visible as non-etched phase.
3

4 The fact of detecting current at TiNbC grains indicates that these grains are electrically
5 connected and form part of a conducting network within the composite. Frajkorová et al.
6 suggested on possibility of formation homogeneously distributed conductive amorphous
7 phase based on Ti-Nb-C-(O-Si) on the SiC grain boundaries which forms continuous
8 network with (Ti, Nb) C_{ss} resulting in enhancement of electrical conductivity [19]. AFM
9 analysis confirmed the suggestions of Frajkorova et al. that the conductive network is
10 formed from TiNbC grains. On the other hand, TEM analysis of our samples did not
11 confirm their suggestion that on the grain boundary there is a Ti-Nb-C-O-Si conductive
12 phase. From our results we can say that conductive phase on the grain boundary is
13 composed from Ti-Nb-(C)-Fe(Co) elements which form alloys.
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31

32 *3.5. Magnetic properties*

33
34
35 It was published, that NbC exhibits superconductivity behavior near 11 K [26-28], TiC
36 could be superconductive near 4 K [29] , so it was interesting to find out how NbC can
37 influence the behavior of SiC/Ti-NbC composite. On this behalf magnetic measurements
38 were carried out on the reference sample of SiC with no additives and also on the SiC
39 with Ti-NbC addition.
40
41
42
43
44
45

46 Fig. 9(a) shows Zero field cool/Field cool (ZFC/FC) magnetization vs. temperature
47 dependence of the prepared samples. Sample SiC ref. exhibits bifurcation of ZFC and FC
48 curve, split of the curves occurs possibly at temperatures higher than 300 K. This
49 bifurcation, together with a wide maximum at the ZFC curve at 70 K, indicates the
50 existence of frustrated system containing ferromagnetic (FM) and antiferromagnetic
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

1 (AFM) interactions. Inverse FC susceptibility $1/\chi(T)$ was analyzed according to the
2
3 Curie-Weiss law:

$$4 \quad \chi - \chi_0 = C/(T - \theta),$$

5
6
7
8 where χ_0 is the temperature independent contribution, C is the Curie-Weiss constant, T is
9
10 the temperature and θ is the Weiss temperature. This gives us the positive value of $\theta_{HT} =$
11
12 112.2 K in high temperature region (HT; 100 – 240 K), implying FM ordering; for the
13
14 low temperature region (LT; 5 – 100 K) a negative value $\theta_{LT} = -102.6$ K was obtained,
15
16
17
18 which means possible AFM interactions.

19
20 Temperature dependence of magnetization for SiCN30 is negative in the region 50 - 300
21
22 K, its $1/\chi_m$ plot is almost linear and gives the value $\theta = 2.14$ K, which means that only
23
24 weak ferromagnetic interaction is present. Plot for SiCN40 shows bifurcation at $T = 45$
25
26 K, obtained Weiss temperatures are $\theta_{HT} = 10.5$ K (30 – 300 K) and $\theta_{LT} = -5.4$ K (5 – 30
27
28 K), so competing FM/AFM interactions are also present. SiCN50 has clearly visible peak
29
30 (blocking temperature) on the ZFC plot and bifurcation at 70 K, signaling stronger
31
32 FM/AFM interactions. Values of Weiss temperature for this sample are $\theta_{HT} = -13.9$ K
33
34 (100 – 300 K) and $\theta_{LT} = 5.5$ K (5 – 100 K). Fig. 9(b) presents low-temperature $M(T)$
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65
behavior of the composites. All of them exhibit strong decrease of magnetization under
2K, where possibly superconducting state is reached.

66
67
68
69
70
71
72
73
74
75
76
77
78
79
80
81
82
83
84
85
86
87
88
89
90
91
92
93
94
95
96
97
98
99
100
Magnetization vs. Field (MH) loops measured at 2 K are presented in the Fig. 10(a). SiC
ref. sample shows FM like behavior with visible hysteresis and saturation, with
diamagnetic contribution at higher field. Samples SiCN30, SiCN40 and SiCN50 are
paramagnetic, with no visible hysteresis, SiCN30 and SiCN40 show also diamagnetic
contribution at higher field. MH loops measured at 300 K (fig. 10(b)) confirmed FM
behaviour of SiC ref. sample, again there is visible diamagnetic slope at high field region.

1 Both SiCN30 and SiCN40 are diamagnetic, SiCN50 shows paramagnetic (PM)
2 behaviour.

3
4
5 Very interesting is the observed superconductivity of SiCN30 and SiCN40. Type-I
6 superconductivity was reported earlier in B-doped 3C-SiC and 6H-SiC under $T_C \sim 1.4$ K
7 (critical temperature) [30], as well as type-II superconductivity in Al-doped 3C-SiC [31].

8
9
10 To confirm our results observed in the ZFC/FC measurements, low-field MH loops were
11 measured at 2 K (fig. 11). SiCN30 shows (fig. 11(a)) the superconductivity, where initial
12 low-field magnetization firstly decreases with field almost linearly and then increases
13 because of superposition of FM component. With increasing of the amount of Ti-NbC
14 phase the superconductive state starts to disappear (SiCN40; Fig. 11(b)) and SiCN50
15 shows at given temperature weak ferromagnetism (fig. 11(c)). We assume that together
16 with the addition of Ti and NbC we incorporate the impurities from the initial powders,
17 especially Fe and Co, which suppress the superconductivity.

18
19
20 It was reported that α -SiC is diamagnetic [32] but defect-induced FM may occur when
21 the SiC is exposed to Xe ion radiation. Also β -SiC was reported as ferromagnetic [33].
22 On the other hand, doping with Al [34] or vanadium carbide [33] could reduce the FM in
23 the SiC. In case of this study, FM in SiC ref. is similar to (Al, Fe) codoped SiC reported
24 earlier [35] and is mainly caused by Fe impurities in the starting powder. Visible
25 diamagnetic slope, both on the 2 K and 300 K MH curves (Fig. 10) indicates that SiC
26 matrix itself is diamagnetic. However, samples with addition of Ti and NbC were
27 prepared from different starting SiC powder (different batch) comparing to SiC ref. and
28 thus obtained recognizable different level of Fe contamination.

29 30 31 32 33 34 35 36 37 38 39 40 41 42 43 44 45 46 47 48 49 50 51 52 53 54 55 56 57 58 **4. Conclusions**

1 Silicon carbide composites with 30, 40 and 50 wt. % of Ti and NbC as sintering
2 additives were prepared by hot-press method. The combination of the planetary ball
3 milling and spraying the suspension into the liquid nitrogen led to homogeneous
4 distribution of conductive phase in the starting powder. The use of the two step sintering
5 process avoided to squeezing out of the melted Ti, which led to prepare of the dense SiC
6 composites with addition of 40 and 50 wt. % of Ti-NbC. Highest electrical conductivity
7 2.4×10^5 S/m was achieved in the composite with addition of 50 wt. % of Ti-NbC by
8 homogeneous distribution of Ti and NbC in SiC matrix and formation of the conductive
9 network from TiNbC grains. Prepared composites show complex magnetic properties,
10 diamagnetism originated from SiC matrix, paramagnetism caused by Ti and NbC
11 admixing, as well as weak ferromagnetism probably coming from impurities contained
12 in the initial powders. Samples with 30 and 40 wt % of Ti and NbC exhibit
13 superconducting state below 2 K. The origin of superconductivity is not yet clear and we
14 will try to explain it in our further work.
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32

33 **Declaration of competing interest**

34
35 The authors declare that they have no known competing financial interests or personal
36 relationships that could have appeared to influence the work reported in this paper.
37
38
39
40
41
42
43

44 **Acknowledgements**

45
46 This study was performed during the implementation of the project Building-up Centre
47 for advanced materials application of the Slovak Academy of Sciences, ITMS project
48 code 313021T081 supported by Research & Innovation Operational Programme funded
49 by the ERDF. This work was partially supported from the European Union's Horizon
50 2020 research and innovation programme under grant agreement No. 810701. The
51 support of VEGA 2/0007/21 and APVV-19-410 projects is also acknowledged.
52
53
54
55
56
57
58
59
60
61
62
63
64
65

1
2 Authors would like to thank Dr. Peter Švec Jr. (Institute of Physics, Slovak Academy of
3 Sciences) for the TEM analysis.
4
5

6 References

7
8 [1] C. Martin, B. Cales, P. Vivier, P. Mathieu, Electrical discharge machinable ceramic
9 composites, *Mater. Sci. Eng. A109* (1989) 351–356. [https://doi.org/10.1016/0921-](https://doi.org/10.1016/0921-5093(89)90614-X)
10 [5093\(89\)90614-X](https://doi.org/10.1016/0921-5093(89)90614-X).

11
12 [2] O. Malek, J. González-Julián, J. Vleugels, W. Vanderauwer, B. Lauwers, M.
13 Belmonte, Carbon nanofillers for machining insulating ceramics, *MaterToday* 14 (2011)
14 496–501. [https://doi.org/10.1016/S1369-7021\(11\)70214-0](https://doi.org/10.1016/S1369-7021(11)70214-0).
15

16
17 [3] B. Lauwers, J.P.Kruth, W. Liu, W. Eeraerts, B. Schacht, P. Bleys, Investigation of
18 material removal mechanisms in EDM of composite ceramic materials, *J. Mater.*
19 *Process. Technol.* 149 (2004) 347–352.
20 <https://doi.org/10.1016/j.jmatprotec.2004.02.013>.
21

22
23 [4] G. Sauti, A. Can, D.S. McLahlan, The AC conductivity of liquid-phase-sintered
24 silicon carbide, *J. Am. Ceram. Soc.* 90 (2007) 2446–2453.
25 <https://doi.org/10.1111/j.1551-2916.2007.01792.x>.
26

27
28 [5] K.J. Kim, K.Y. Lim, Y.W. Kim, M.J. Lee, W.S. Seo, Electrical resistivity of α -SiC
29 ceramics sintered with Al₂O₃ or AlN additives, *J. Eur. Ceram. Soc.* 34 (2014) 1695–
30 1701. <https://doi.org/10.1016/j.jeurceramsoc.2014.01.004>.
31

32
33 [6] G.D. Zhan, M. Mitomo, A.K. Mukherjee, Effects of heat treatment and sintering
34 additives on thermal conductivity and electrical resistivity in fine-grained SiC ceramics,
35 *J. Mater. Res.* 17 (2002) 2327–2333. <https://doi.org/10.1557/JMR.2002.0341>.
36

37
38 [7] A. Can, D.S. McLachlan, G. Sauti, M. Herrmann, Relationships between
39 microstructure and electrical properties of liquid-phase sintered silicon carbide materials
40 using impedance spectroscopy, *J. Eur. Ceram. Soc.* 27 (2007) 1361–1363.
41 <https://doi.org/10.1016/j.jeurceramsoc.2006.05.053>.
42

43
44 [8] F. Siegelin, H.J. Kleebe, L.S. Sigl, Interface characteristics affecting electrical
45 properties of Y-doped SiC, *J. Mater. Res.* 18 (2003) 2608–2617.
46 <https://doi.org/10.1557/JMR.2003.0365>.
47

48
49 [9] Y.W. Kim, S. Kultayeva, J. Sedláček, O. Hanzel, P. Tatarko, Z. Lenčėš, P. Šajgalík,
50 Thermal and electrical properties of additive-free rapidly hot-pressed SiC ceramics, *J.*
51 *Eur. Ceram. Soc.* 40 (2020) 234–240.
52 <https://doi.org/10.1016/j.jeurceramsoc.2019.10.015>.
53

54
55 [10] Y.W. Kim, K. J. Kim, H.C. Kim, N.H. Cho, K.Y. Lim, Electrodischarge-
56 machinable silicon carbide ceramics sintered with yttrium nitrate, *J. Am. Ceram. Soc.*
57 94 (2011) 991–993. <https://doi.org/10.1111/j.1551-2916.2011.04419.x>.
58
59
60
61
62
63
64
65

- 1 [11] M. Michálek, J. Sedláček, M. Parchoviansky, M. Michálková, D. Galusek,
2 Mechanical properties and electrical conductivity of alumina/MWCNT and
3 alumina/zirconia/MWCNT composites, *Ceram. Int.* 40 (2014) 1289-1295.
4 <https://doi.org/10.1016/j.ceramint.2013.07.008>.
- 5 [12] O. Hanzel, J. Sedláček, P. Šajgalík, New approach for distribution of carbon
6 nanotubes in alumina matrix, *J. Eur. Ceram. Soc.* 34 (2014) 1845–1851.
7 <https://doi.org/10.1016/j.jeurceramsoc.2014.01.020>.
- 8 [13] A. Kovalčíková, Cs. Balázs, J. Dusza, O. Tapasztó, Mechanical properties and
9 electrical conductivity in a carbon nanotube reinforced silicon nitride composite, *Ceram.*
10 *Int.* 38 (2012) 527–533. <https://doi.org/10.1016/j.ceramint.2011.07.038>.
- 11 [14] Cs. Balázs, B. Fényi, N. Hegman, Zs. Kövér, F. Weber, Z. Vértesy, Z. Kónya, I.
12 Kiricsi, L.P. Biró, P. Arató, Development of CNT/Si₃N₄ composites with improved
13 mechanical and electrical properties, *Composites: Part B* 37 (2006) 418–424.
14 <https://doi.org/10.1016/j.compositesb.2006.02.006>.
- 15 [15] K. Lee, Ch.B. Mo, S.B. Park, S.H. Hong, Mechanical and electrical properties of
16 multiwalled CNT-Alumina nanocomposites prepared by a sequential two-step
17 processing of ultrasonic spray pyrolysis and spark plasma sintering, *J. Am. Ceram. Soc.*
18 94 (2011) 3774–3779. <https://doi.org/10.1111/j.1551-2916.2011.04689.x>.
- 19 [16] G. Yamamoto, M. Omori, T. Hashida H. Kimura, A novel structure for carbon
20 nanotube reinforced alumina composites with improved mechanical properties,
21 *Nanotech.* 19 (2008) 315708-315713. <https://doi.org/10.1088/0957-4484/19/31/315708>.
- 22 [17] B. Román-Manso, E. Domingues, F.M. Figueiredo, M. Belmonde, P. Miranzo,
23 Enhanced electrical conductivity of silicon carbide ceramics by addition of graphene
24 nanoplatelets, *J. Eur. Ceram. Soc.* 35 (2015) 2723-2731.
25 <https://doi.org/10.1016/j.jeurceramsoc.2015.03.044>.
- 26 [18] S.J. Schneider Jr., *Engineered Materials Handbook, Vol. 4, Ceramics and Glasses,*
27 ASM International, USA, 1991.
- 28 [19] F. Frajkorová, Z. Lenčేశ, P. Šajgalík, Electrically conductive silicon carbide
29 without oxide sintering additives, *J. Kor. Ceram. Soc.* 49 (2012) 342-346.
30 <https://doi.org/10.4191/kcers.2012.49.4.342>.
- 31 [20] M. Balog, P. Šajgalík, F. Hofer, P. Warbichler, K. Frohlich, O. Vávra, J. Janega,
32 J.L. Huange, Electrically conductive SiC–(Nb,Ti)_{ss}–(Nb,Ti)C_{ss} cermet, *J. Eur. Ceram.*
33 *Soc.* 26 (2006) 1259–1266. <https://doi.org/10.1016/j.jeurceramsoc.2005.01.038>
- 34 [21] P. Šajgalík, J. Sedláček, Z. Lenčేశ, J. Dusza, H.T. Lin, Additive-free hot-pressed
35 silicon carbide ceramics-A material with exceptional mechanical properties, *J. Eur.*
36 *Ceram. Soc.* 36 (2016) 1333-1341. <https://doi.org/10.1016/j.jeurceramsoc.2015.12.013>.
- 37 [22] L.J. van der Pauw, A method of measuring specific resistivity and hall effect of
38 discs of arbitrary shape, *Philips Res. Repts* 13(1958) 1-9.

1 [23] K. Rajan, P. Šajgalík, Local chemistry changes in Si₃N₄ based ceramics during hot-
2 pressing and subsequent annealing, *J. Eur. Ceram. Soc.* 19 (1999) 2027–2032.
3 [https://doi.org/10.1016/S0955-2219\(99\)00014-X](https://doi.org/10.1016/S0955-2219(99)00014-X).

4 [24] L. Rokhlin, Cobalt-Iron-Silicon, in: G. Effenberg, S. Ilyenko, Ternary Alloy
5 Systems, Springer Berlin Heidelberg, New York, 2008, pp. 1-26.

6 [25] J.H. Eom, Y.W. Kim, K.J. Kim, W.S. Seo, Improved electrical and thermal
7 conductivities of polysiloxane-derived silicon oxycarbide ceramics by barium addition,
8 *J. Eur. Ceram. Soc.* 38 (2018) 487–493.
9 <https://doi.org/10.1016/j.jeurceramsoc.2017.09.045>.

10 [26] M. Wells, M. Pickus, K. Kennedy, V. Zackay, Superconductivity of solid solutions
11 of TaC and NbC, *Phys. Rev. Lett.* 12 (1964) 536-538.
12 <https://doi.org/10.1103/PhysRevLett.12.536>.

13 [27] H.X. Geng, G.C. Che, W.W. Huang, S.L. Jia, H. Chen, Z.X. Zhao, Structural,
14 morphological, C content and *T_C* changes of the NbC superconductor prepared by Nb
15 powder and carbon nanotubes, *Supercond. Sci. Technol.* 20 (2007) 211–215.
16 <https://doi.org/10.1088/0953-2048/20/3/016>.

17 [28] R. Jha, V.P.S. Awana, Vacuum encapsulated synthesis of 11.5 K NbC
18 superconductor, *J. Supercond. Nov. Magn.* 25 (2012) 1421–1425.
19 <https://doi.org/10.1007/s10948-012-1654-6>.

20 [29] N. Guskos, V. Likodimos, S. Glenis, G. Zolnierkiewicz, J. Typek, C.L. Lin, A.
21 Biedunkiewicz,
22 Magnetic properties of TiC_x/C nanocomposites, *J. Non Cryst. Solids* 354 (2008) 4330-
23 4333. <https://doi.org/10.1016/j.jnoncrystal.2008.06.046>.

24 [30] Z. A. Ren, J. Kato, T. Muranaka, J. Akimitsu, M. Kriener, Y. Maeno, 2007.
25 Superconductivity in boron-doped SiC, *J. Phys. Soc. Jpn.* 76, 103710.
26 <https://doi.org/10.1143/JPSJ.76.103710>.

27 [31] T. Muranaka, Y. Kikuchi, T. Yoshizawa, N. Shirakawa, J. Akimitsu, 2008.
28 Superconductivity in carrier-doped silicon carbide, *Sci. Technol. Adv. Mater.* 9,
29 044204. <https://doi.org/10.1088/1468-6996/9/4/044204>

30 [32] Y. Wang, Y. Liu, G. Wang, W. Anwand, C.A. Jenkins, E. Arenholz, F. Munnik,
31 O.D. Gordan, G. Salvan, D.R.T. Zahn, X. Chen, S. Gemming, M. Helm, S. Zhou, 2015.
32 Carbon *p* electron ferromagnetism in silicon carbide. *Sci. Rep.* 5, 8999.
33 <https://doi.org/10.1038/srep08999>.

34 [33] H. Wang, Ch. Yan, H. Kong, J. Chen, J. Xin, E. Shi, Influence of mole ratio of
35 Si:C on the magnetic property of undoped and vanadium carbide doped 3C-SiC, *Chem.*
36 *Phys. Lett.* 556 (2013) 142-145. <https://doi.org/10.1016/j.cplett.2012.12.008>.

37 [34] C. Zhang, J. Lian, H.L.Ng. Dickon, Magnetic properties of Al-doped B₄C and SiC
38 ceramics, *J. Amer. Ceram. Soc.* 96 (2013) 3494-3499.
39 <https://doi.org/10.1111/jace.12510>.

1 [35] B. Song, X.L. Chen, J.C. Han, J.K. Jian, H.Q. Bao, H. Li, K.X. Zhu, W.Y. Wang,
2 G. Wang, H.B. Zuo, (2010). Structural and magnetic properties of (Al, Fe)-codoped
3 SiC, J. Phys. D: Appl. Phys. 43, 415002. <https://doi.org/10.1088/0022->
4 [3727/43/41/415002](https://doi.org/10.1088/0022-3727/43/41/415002).
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

Tables

Tab. 1 Impurities in the initial powders

Element	SiC	NbC	Ti
	ppm	ppm	ppm
Ca	594	227	245
Fe	2150	1190	1260
Co	–	535	–
Al	3130	448	428
Si	99	113	482

Tab. 2 Chemical composition of starting mixtures

Sample	W [wt. %]		
	SiC	Ti	NbC
SiC30TiNbC	70	10.8	19.2
SiC40TiNbC	60	14.4	25.6
SiC50TiNbC	50	18.0	32.0

1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

Tab. 3 Density of initial powders

Powder	SiC	Ti	NbC
ρ [g/cm ³]	3.21	4.51	7.8

1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

Tab. 4 The density and relative density of reference SiC [21] and composites after sintering at 1850 °C

Sample	ρ [g/cm³]	TD [%]
SiC ref.	3.21	99.9
SiCN30	3.44	91.7
SiCN40	3.86	97.2
SiCN50	4.14	98.3

1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

Figures

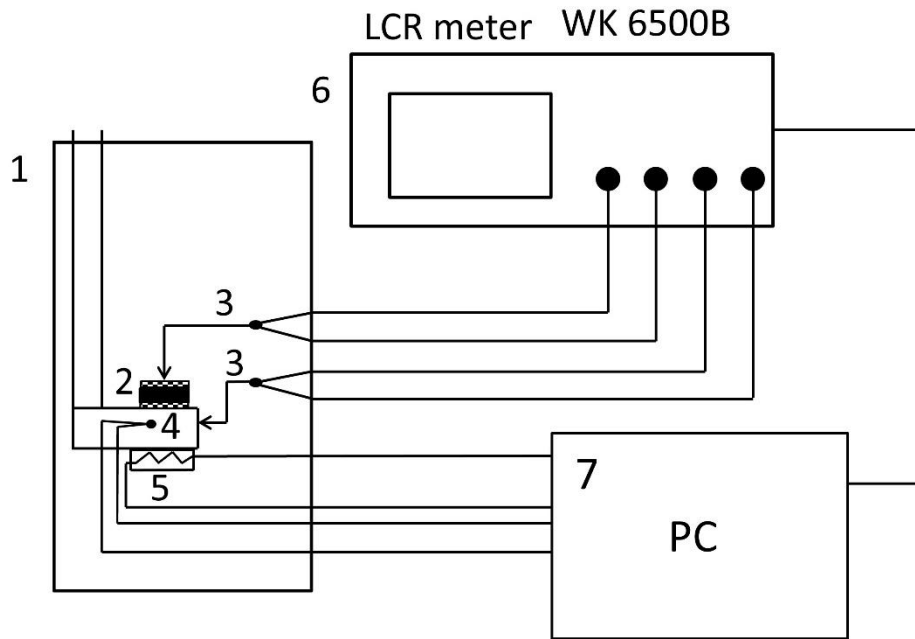


Fig. 1 Schematic diagram of temperature dependent conductivity measurement. The heated holder is (1), which is composed from the sample holder (2), probes (3), thermocouple (4) and the resistor heater (5). LCR meter is (6), PC is personal computer (7).

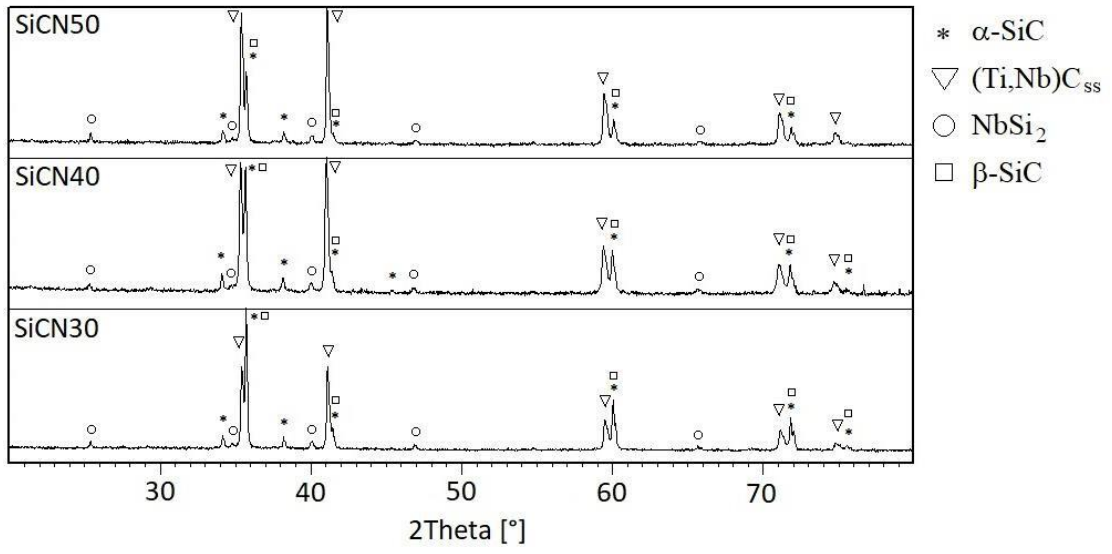


Fig. 2 Comparison of XRD patterns of sintered samples

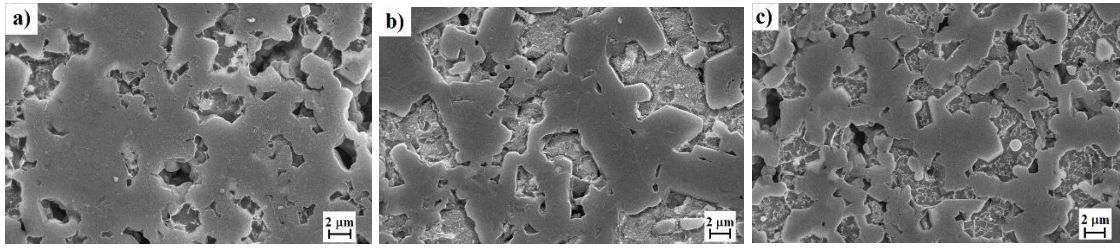


Fig. 4 The microstructures of sintered samples SiCN30 (a), SiCN40 (b), SiCN50 (c), dark grey represents SiC grains, (Ti, Nb)C_{ss} grains are overetched

1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

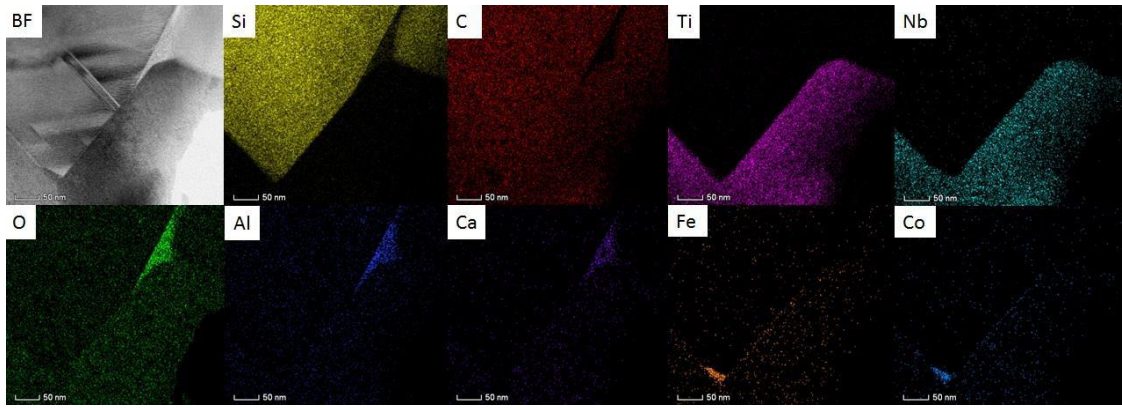


Fig. 5 TEM image and EDX map image of the sample SiCN50

1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

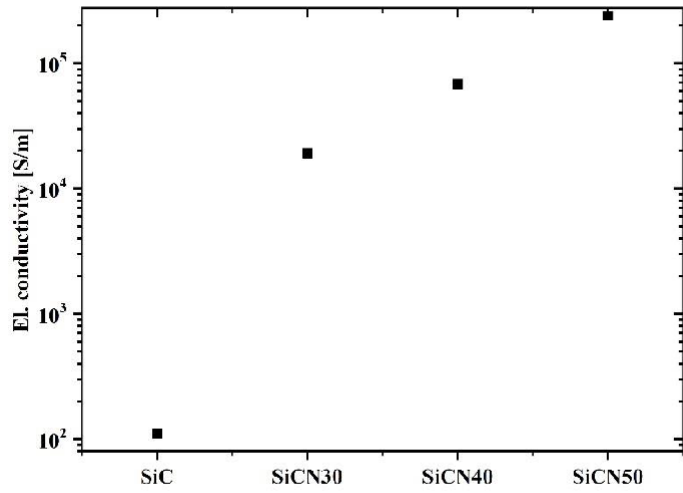


Fig. 6 Room temperature electrical conductivity of composites as a function of TiNbC content

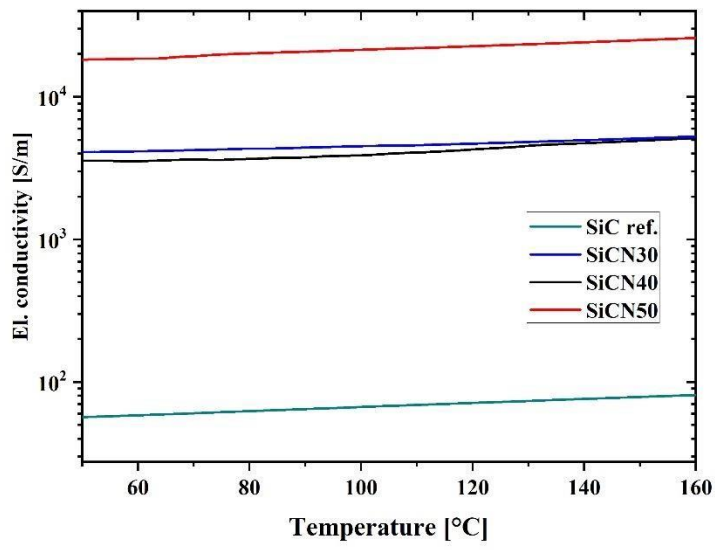


Fig. 7 Temperature dependence of the electrical conductivity of the various samples

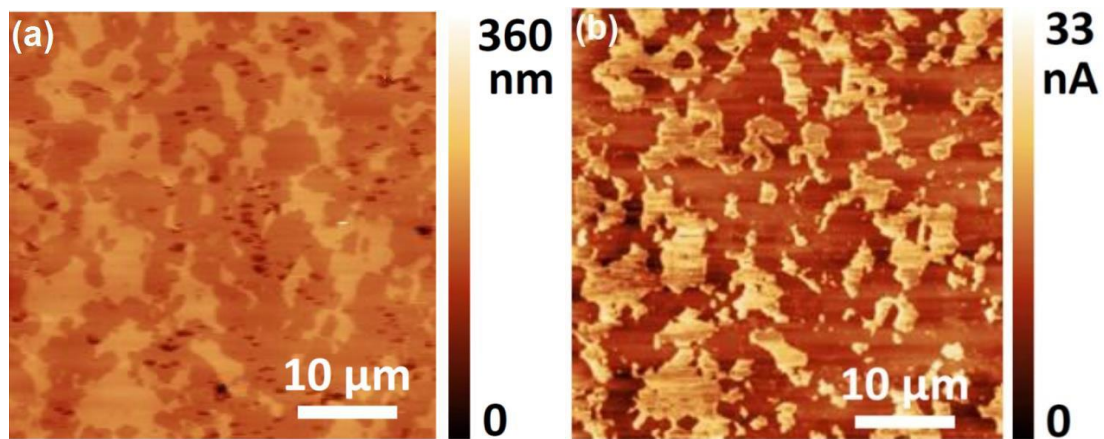


Fig. 8 Topography of SiCN50 (a) and current map of the same surface area acquired at $V_{tip} = + 2.5$ V (b)

1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
61
62
63
64
65

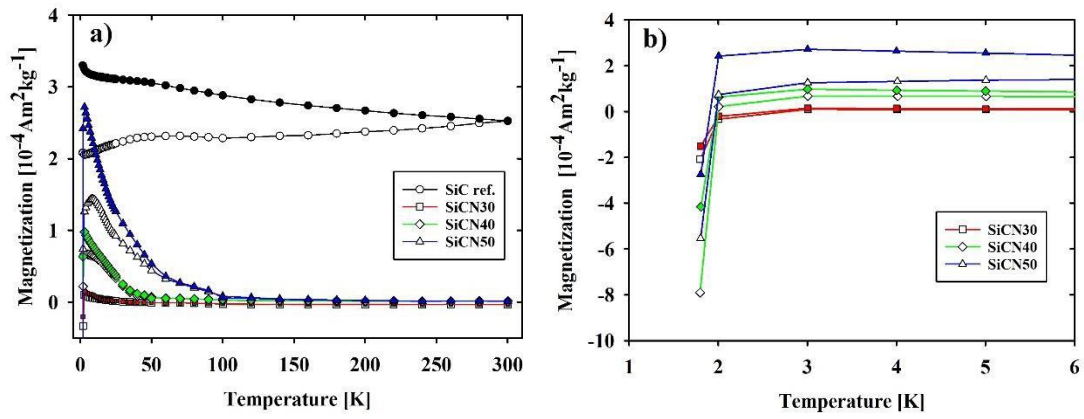


Fig. 9 ZFC (empty symbols) and FC (full symbols) curves for SiC ref. (circle), SiCN30 (square), SiCN40 (diamond), SiCN50 (triangle) (a), enlarged view of the low-temperature part of the ZFC and FC curves (b).

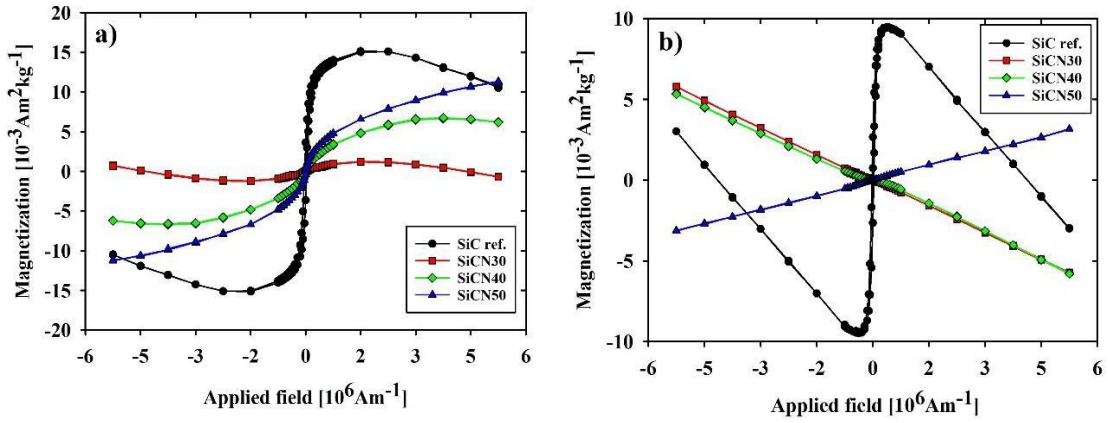


Fig. 10 MH loops measured at 2 K (a) and 300 K (b) for SiC_{ref} (circle), SiCN30 (square), SiCN40 (diamond), SiCN50 (triangle).

11 **Fig. 11** Low-field MH loops measured at 2 K for SiCN30 (a), SiCN40 (b) and SiCN50.

